# STRONG DEPENDENCE OF ELECTRON KINETICS IN COLLISION DOMINATED He-CO of PLASMA ON DIFFERENT ADMIXTURES OF CO')

WINKLER R.,<sup>2)</sup> WILHELM J.,<sup>2)</sup> Greifswald, DILONARDO M.,<sup>3)</sup> CAPITELLI M.,<sup>3)</sup>
GORSE C.,<sup>3)</sup> Bari

Electron energy distribution functions and mean collision frequencies for the uniform bulk plasma of established rf discharges in He/CO have been obtained by solving the time dependent Boltzmann equation. The results, which are of importance for plasma processing and laser technology, show that already small CO admixtures to Hc remarkably change the periodic behaviour of the energy distribution of the electrons by a drastic enhancement of the collisional energy dissipation effectiveness in the mixture. These changes can be interpreted on the basis of a lumped energy dissipation frequency in all electron collisions, which is determined by the atomic data of the electron collsion processes as well as by the admixture fractions and which drastically increases with an increasing CO admixture.

### I. INTRODUCTION

The modelling of strongly time dependent plasmas (radio frequency, microwave, pulse-like ones) used for plasma technology (etching, deposition, laser medium) has clearly indicated the large importance of a detailed knowledge of the non-stationary electron velocity distribution function, in particular of the isotropic part of the latter, and of the resultant mean collision frequencies for the main electron impact reactions as excitation, dissociation and ionization of a particular feed gas [1], [2].

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By an exact solution of the time dependent, spatially uniform Boltzmann equation, the isotropic distribution (ID) in the bulk of rf discharges in inert and molecular gases has been comprehensively studied [3—6]. However, in application to plasma technology one uses discharges in mix-

8—10, 2200 GREIFSWALD, GDR
 3) Centro di Studio per la Chimica dei Plasmi del C.N.R., Via G. Amendola 173, 70126 BAR1,
 11-11.

<sup>2</sup>) Zentralinstitut für Elektronenphysik, AdW Bereich Gasentladungsphysik, Robert-Blum-Str.

tures containing often only a small admixture of a molecular component to an

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inert gas. This paper reports isotropic distributions and relevant macroscopic quantities for the bulk plasma of an rf discharge in He/CO mixtutes in comparison with the corresponding quantities relevant to pure He and CO.

## II. BOLTZMANN EQUATION AND LUMPED DISSIPATION FREQUENCIES OF A MIXTURE PLASMA

The basic equation for the He/CO mixture is the non-stationary, spatially uniform Boltzmann equation for the electron velocity distribution F(v, t)

$$\frac{\partial F}{\partial t} - \frac{e_0}{m} \underline{F} \cdot \frac{\partial F}{\partial \underline{v}} = \sum_{i} \left( C_i^{e_i} + \sum_{k} C_{j,k}^{in} \right) \tag{1}$$

in the rf field

$$\underline{E} = E_{\underline{e}_z}, \qquad E(t) = E_0 \cos(\omega t). \tag{2}$$

In (1) the index j refers to the component j, i.e. to He and CO, respectively and the meaning of the other symbols is the usual one [4].

The Legendre polynomial expansion of  $F(\underline{v}, t)$  in (1) gives in the Lorentz approximation finally two partial differential equations for the isotropic part and for the first contribution to the anisotropic part of  $F(\underline{v}, t)$ , generalized for a mixture plasma.

As already it has been successfully done for rf plasmas in pure gases [4], the results for the mixture will be interpreted in terms of two normalized lumped frequencies for the energy and the impulse dissipation in all electron collisions. For the generalized case of a mixture they are given by

$$\frac{v_{c}(U)}{p_{0}} = \sum_{j} \frac{N_{j}}{N} \left( 2 \frac{m}{M_{j}} \frac{v_{j,d}(U)}{p_{0,j}} + \sum_{k} \frac{v_{j,k}^{m}(U)}{p_{0,j}} \right) = \sum_{j} \frac{N_{j}}{N} \left( \frac{v_{c}(U)}{p_{0}} \right)_{j}$$

$$\frac{v_{j}(U)}{p_{0}} = \sum_{j} \frac{N_{j}}{N} \left( \frac{v_{j,d}(U)}{p_{0,j}} + \sum_{k} \frac{v_{j,k}^{m}(U)}{p_{0,j}} \right) = \sum_{j} \frac{N_{j}}{N} \left( \frac{v_{j}(U)}{p_{0}} \right)_{j}.$$
(3)

In these relations again the index j refers to the two components and  $v_{j,d}$  and  $v_{j,d}^{T}$  are represent the collision frequency for the impulse transfer in elastic collisions and for the kth inelastic collision process with the component j, which are dependent on the electron energy.

For example  $v_{j,k}^{in} = vN_jQ_{j,k}^{in}(v)$ , where  $N_j$  is the density of the gas component j and  $Q_{j,k}^{in}(v)$  the total cross section for the kth inelastic collision process of the electrons with molecules of the component j. U means the instantaneous electron energy in eV  $(e_0U = mv^2/2)$  and

$$p_0 = \sum_i p_{0,i}, \quad p_{0,i} = N_i / n_g, \quad N = p_0 n_g \quad (n_g = 3.54 \times 10^{16} \,\text{cm}^{-3} \,\text{Torr}^{-1})$$

denote the total gas pressure of the mixture, the partial pressures of the components (all at 0 °C) and the total gas density. Due to the normalization of  $v_i$  and  $v_i$  on  $p_0$  the dissipation frequencies  $v_i/p_0$  and  $v_i/p_0$  are determined by the different collision cross sections, the ratios  $m/M_j$  of the electron mass to the gas particle mass and the admixture fractions  $N_j/N$  of the components, i.e. only by the atomic data of the collision processes and the admixture fractions.

Both these lumped dissipation frequencies describe the effectiveness of the energy and impulse dissipation of the electrons in their energy space by all collision processes. Thus the rapidity of the alteration of the rf field, which is characterized by the normalized field frequency  $\omega/p_0$ , determines in relation to both normalized lumped dissipation frequencies the degree of modulation and the corresponding phase shift of the ID with respect to the rf field and of the relevant macroscopic quantities [4], [5].

Especially for  $\omega/p_0 \ll \nu_e/p_0$  a quasistationary behaviour of the ID with a very large modulation occurs, whilst for the reverse relation  $\omega/p_0 \gg \nu_e/p_0$  the ID becomes practically time independent.

### III. RESULTS AND INTERPRETATION

The partial differential equations resulting from the Legendre polynomial expansion of (1) have been solved numerically up to the establishing of the periodic state by applying the collision cross sections of CO used in [5] and of He used in [7]. The calculations of ID and the relevant macroscopic quantities

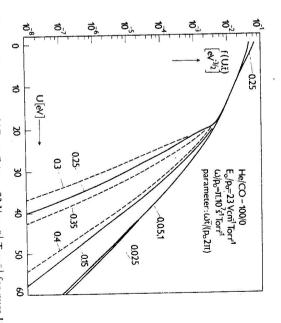


Fig. 1. Periodic behaviour of ID at  $E_0/p_0 = 23 \text{ V cm}^{-1} \text{ Torr}^{-1}$  for pure He.

have been performed for a normalized field frequency value of  $\omega_l$   $p_0 = \pi \times 10^7 \, \text{s}^{-1} \, \text{Torr}^{-1}$  relevant to the rf discharge plasmas in the MHz region. Now we discuss the periodic behaviour of ID for a relatively large field amplitude of  $E_0/p_0 = 23 \, \text{V cm}^{-1} \, \text{Torr}^{-1}$ , which is more typical of the rf plasma processing. As in the case of the one component rf discharge plasma a normalized time scale  $\bar{t} = p_0 t$  can be introduced also in a mixture.

Fig. 1 shows the periodic evolution of ID in pure He with  $\omega l/(p_0 2\pi) = t/T$  (T being the period of the rf field) as a parameter of the curves. The corresponding energy distribution of the electrons is directly obtained by ID, i.e. by the multiplication of ID with the square root  $U^{1/2}$  of the electron energy. As obvious the modulation of the ID is almost absent in the region of the low energies up to 20 eV, while a remarkable modulation is present in the region of the electronic excitation and the ionization of He.

Fig. 2 reports ID's periodic behaviour for a mixture containing 10% CO. Now, a remarkable modulation occurs also at lower energies despite the small admixture fraction of only 10%. Moreover the ID is on the period average much more depopulated at higher electron energies.

Finally Fig. 3 shows the periodic behaviour of ID in the limiting case of pure CO. Now, extremely large modulations of ID occur at energies around 2 eV and above 6 eV and large temporal alteration in the intermediate range.

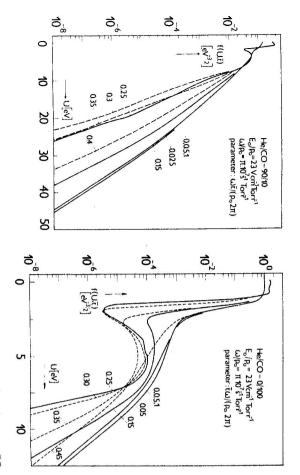


Fig. 2. Periodic behaviour of ID at 10% CO Fig. 3. Periodic behaviour of ID for pure CO admixture.

These figures clearly indicate a very strong change of ID's periodical behaviour at the fixed field frequency  $\omega/p_0$  and the field amplitude  $E_0/p_0$  when passing from an rf plasma in pure He via the He/CO mixtures to pure CO. This behaviour can be microphysically interpreted on the basis of the relation of the field frequency  $\omega/p_0$  to the lumped energy dissipation frequency  $v_c/p_0$ . To that end Fig. 4 reports the normalized lumped frequencies for impulse and energy dissipation for pure He, for a He/CO mixture with 10% CO admixture and for pure CO. In pure He large values of the lumped energy dissipation frequency only occur in the energy region of intense electronic excitation, i.e. above 20 eV.

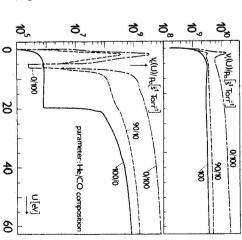


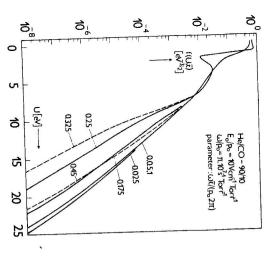
Fig. 4. Normalized lumped frequencies  $v_i(U)/p_0$  and  $v_s(U)/p_0$  for impulse and energy dissipation as dependent on the electron energy.

The presence of a small CO admixture considerably increases the lumped energy dissipation frequency  $v_e/p_0$ , mainly in the energy region of 0—20 eV. In particular, the strong peak at about 2 eV in  $v_e/p_0$  is due to an intense vibrational excitation in CO, and the large enhancement in  $v_e/p_0$  above 6 eV, especially between 6 and 20 eV is due to a large electronic excitation, dissociation and ionization in CO. In addition Fig. 4 shows a further pronounced increase of the normalized energy dissipation frequency when going from a 10% CO admixture to the pure CO case due to the very different magnitude of the collision cross sections in He and CO and therefore of the lumped energy dissipation frequency relevant to these pure gases. As a consequence of this large change in the lumped energy dissipation frequency with the CO admixture we have at not too large field frequencies  $\omega/p_0$  (i.e. at  $\pi \times 10^7$  considered) in pure He large modulation of ID only in the high energy region, i.e. above 20 eV. For energies below the threshold the lumped energy dissipation frequency for inelastic collision

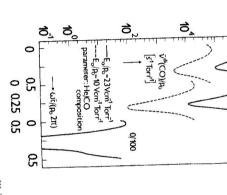
energy dissipation at higher energies due to the excitation and the ionization of processes in He (19.5 eV) is much smaller than the considered field frequency remarkably larger than the considered field frequency  $\omega/p_0$  so that there still  $\omega/p_0$ , while the reverse is true above the threshold. Thus a rapid collisional CO admixture  $v_e/p_0$  becomes for energies around 2 eV and above 6 eV already the atoms occurs, however, is no longer possible at lower energies. For a 10%to the observed large modulation and the depopulation of the ID on the period occurs a rapid collisional energy dissipation in these energy regions, which leads effects on the ID are, of course, still much more pronounced. average at higher electron energies. Finally, for pure CO the just mentioned

energies. Generally for laser applications one requires mainly electrons at lower energies (of a few eV), so that one must consider rf plasmas with lower rf field ID's so far reported, have a large portion of electrons with relatively high

amplitudes.



 $p_0 = 10 \text{ V cm}^{-1} \text{ Torr}^{-1}$  and at 10% CO admix-Fig. 5. Periodic behaviour of ID at  $E_0/$ 



frequency  $\vec{v}^d(CO)/p_0$  for dissociation of CO at Fig. 6. Periodic behaviour of the mean collision the two field strength values considered.

similar periodic behaviour of ID with a large modulation is obtained, as in 10 V cm<sup>-1</sup> Torr<sup>-1</sup>. As one can appreciate, at the smaller rf electric field a ID at the same field frequency, however, at the smaller field amplitude of Therefore, Fig. 5 reports for a 10% CO admixture the periodic evolution of

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by means of the lumped energy dissipation frequency can be used Fig. 2. Thus for such a decreased  $E_0/p_0$  the same interpretation of this behaviour

strengths with an increasing CO admixture the mean collision frequency ture components. To give at least one example, Fig. 6 reports for two field frequencies for the different inelastic electron collision processes with the mix-ID's is also reflected in the periodic behaviour of relevant mean collision 11.09 eV. A monotone decrease of this collision frequency occurs with growing  $\vec{v}^{i}(CO)/p_0$  for the dissociation of the CO molecules with a threshold energy of ly to the CO admixture fraction. CO admixture despite that this mean collision frequency increases proportional The great impact of different CO admixtures on the periodic behaviours of

of ID at higher energies. the growing CO admixture results due to the correspondingly larger modulation Furthermore, a remarkable increase of the modulation of this quantity with

plasmas with an increasing CO admixture. This sensitivity is mainly caused by the established rf plasma results when passing, at an uncharged field amplitude periodic behaviour of the ID and of the resultant mean collision frequencies in dence must be taken into account when modelling such mixture plasmas. when adding CO, already at very small Co admixtures. This sensitive depenthe drastic change of the collisional energy dissipation effectiveness of pure He  $E_0/p_0$  and field frequency  $\omega/p_0$ , from an rf plasma in pure He to He/CO mixture Concluding we would like to emphazise that a sensitive alteration of the

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### СИЛЬНАЯ ЗАВИСИМОСТЬ КИНЕТИКИ ЭЛЕКТРОНОВ В He-CO r ПЛАЗМЕ С ДОМИНИРУНЦИМИ СОУДАРЕНИЯМИ ОТ РАЗЛИЧНЫХ ПРИМЕСЕЇ

Функции распределения энергии электрона и средняя частота соударений для однород ного объема плазмы установленных гf разрядов в Ne/CO были получены решением завися щего от времени уравнения Больцманна. Результаты, которы играют важную роль в плазменной обработке и лазерной технологии, показывают, что даже маленькая добавка CO в Н существенно меняет периодическое поведение распределения энергии электронов сильных увеличением эффективности диссипации энергии соударений в смеси. Эти изменения можнобъяснить на основе частоты диссипации общей энергии во всех электронных соударениях которая определяется как атомными данными для процессов столкновений электронов, та; и долями примесей, и которая существенно увеличивается с увеличением примеси CO.